

L Number	Hits	Search Text	DB	Time stamp
1	3	4222345.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 08:43
2	2	3939798.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 08:45
3	5	((("3664295") or ("3636916") or ("3608519") or ("2456708") or ("2391595")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 08:47
4	11	"3,939,798"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:04
5	270	(118/719.ccls. or 156/345.31.ccls. or 156/345.32.ccls.) and (jet or nozzle)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:32
6	1	((jet or nozzle) same plasma) and bernouli	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:33
7	3	((jet or nozzle) and plasma) and bernouli	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:33
8	5	plasma and bernouli	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:35
9	3375	plasma and vortex	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:55
10	262	(plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:36
11	9	(plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with article) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:52
12	3	((("6203661") or ("6095582") or ("6040548")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:52
13	23	(plasma or vortex) and bernouli	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:56
14	23	(plasma or vortex) and bernouli not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 09:59
15	4331	((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:40

16	575	(((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:03
17	133	zervigon.xa.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:13
18	421	(((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:40
19	1802	((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:40
20	1761	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:40
21	487	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor)) and (wafer or substrate or article or work or semiconductor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:49
22	5	279/\$.ccls. and (bernouli or vortex)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:52
23	0	"bernouli chuck"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:56
24	1166	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:58
25	860	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996 not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor)) and (wafer or substrate or article or work or semiconductor))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:58

(bernouli or vortex) all word

26	271	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996 not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor))) and (jet or nozzle)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 11:59
27	39	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996 not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor))) and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:01
28	252	(((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996 not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor))) and (jet or nozzle)) not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and @ay<1996 not (((vortex or bernouli) with (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) not (((vortex or bernouli) same (stage or support or platen or table or susceptor or chuck or holder or mandrel)) not ((plasma and vortex) and ((stage or support or platen or table or susceptor or chuck or holder or mandrel) with (wafer or substrate)))) and (plasma or ioniz\$5)) and (wafer or substrate or article or work or semiconductor))) and plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:03
-	8424	118/715.ccls. or 118/728.ccls. or 118/50.ccls. or 156/345.29.ccls. or 156/345.33.ccls. or 156/345.34.ccls. or 156/345.35.ccls. or 156/345.36.ccls. or 156/345.26.ccls. or 156/345.51.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 08:34
-	7990	137/262-264.ccls. or 137/454.2 or 137/560.ccls. or 137/561.ccls. or 137/561a.ccls. or 137/571-576.ccls. or 137/590.ccls. or 137/594-596.ccls. or 137/599.01.ccls. or 137/599.05-599.07.ccls. or 137/602.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35
-	2239	141/285-286.ccls. or 141/37.ccls. or 141/44-47.ccls. or 141/54.ccls. or 141/301-302.ccls. or 141/367.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35
-	453	261/127.ccls. or 261/131.ccls. or 261/146-147.ccls. or 261/150.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35

-	2567	261/19-22.ccls. or 261/23.1.ccls. or 261/40.ccls. or 261/42.ccls. or 261/62-63.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35
-	6993	261/64.1.ccls. or 261/65.ccls. or 261/75-76.ccls. or 261/94-96.ccls. or 261/100-102.ccls. or 261/105.ccls. or 261/108-109.ccls. or 261/113.ccls. or 261/114.1.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35
-	28016	(118/715.ccls. or 118/728.ccls. or 118/50.ccls. or 156/345.29.ccls. or 156/345.33.ccls. or 156/345.34.ccls. or 156/345.35.ccls. or 156/345.36.ccls. or 156/345.26.ccls. or 156/345.51.ccls.) or (137/262-264.ccls. or 137/454.2 or 137/560.ccls. or 137/561r.ccls. or 137/561a.ccls. or 137/571-576.ccls. or 137/590.ccls. or 137/594-596.ccls. or 137/599.01.ccls. or 137/599.05-599.07.ccls. or 137/602.ccls.) or (141/285-286.ccls. or 141/37.ccls. or 141/44-47.ccls. or 141/54.ccls. or 141/301-302.ccls. or 141/367.ccls.) or (261/127.ccls. or 261/131.ccls. or 261/146-147.ccls. or 261/150.ccls.) or (261/19-22.ccls. or 261/23.1.ccls. or 261/40.ccls. or 261/42.ccls. or 261/62-63.ccls.) or (261/64.1.ccls. or 261/65.ccls. or 261/75-76.ccls. or 261/94-96.ccls. or 261/100-102.ccls. or 261/105.ccls. or 261/108-109.ccls. or 261/113.ccls. or 261/114.1.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:35
-	8	((118/715.ccls. or 118/728.ccls. or 118/50.ccls. or 156/345.29.ccls. or 156/345.33.ccls. or 156/345.34.ccls. or 156/345.35.ccls. or 156/345.36.ccls. or 156/345.26.ccls. or 156/345.51.ccls.) or (137/262-264.ccls. or 137/454.2 or 137/560.ccls. or 137/561r.ccls. or 137/561a.ccls. or 137/571-576.ccls. or 137/590.ccls. or 137/594-596.ccls. or 137/599.01.ccls. or 137/599.05-599.07.ccls. or 137/602.ccls.) or (141/285-286.ccls. or 141/37.ccls. or 141/44-47.ccls. or 141/54.ccls. or 141/301-302.ccls. or 141/367.ccls.) or (261/127.ccls. or 261/131.ccls. or 261/146-147.ccls. or 261/150.ccls.) or (261/19-22.ccls. or 261/23.1.ccls. or 261/40.ccls. or 261/42.ccls. or 261/62-63.ccls.) or (261/64.1.ccls. or 261/65.ccls. or 261/75-76.ccls. or 261/94-96.ccls. or 261/100-102.ccls. or 261/105.ccls. or 261/108-109.ccls. or 261/113.ccls. or 261/114.1.ccls.)) and planetary and (boat or carrier) and (plasma or ion)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/10 16:36